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(12) **United States Design Patent**  
**De Castro**(10) **Patent No.:** **US D735,418 S**  
(45) **Date of Patent:** \*\* Jul. 28, 2015(54) **FACE MASK**(71) Applicant: **Marcial Fernando De Castro**, Hialeah, FL (US)(72) Inventor: **Marcial Fernando De Castro**, Hialeah, FL (US)(\*\*) Term: **14 Years**(21) Appl. No.: **29/475,213**(22) Filed: **Dec. 2, 2013****Related U.S. Application Data**

(63) Continuation-in-part of application No. 14/072,035, filed on Nov. 5, 2013.

(51) **LOC (10) Cl.** ..... **16-06**(52) **U.S. Cl.**USPC ..... **D29/108; D29/122; D16/301; D21/660**(58) **Field of Classification Search**

USPC ..... D16/101, 300–342, 900; D29/109–110, D29/108, 122; 351/41, 44, 51–52, 62, 158, 351/92, 103–123, 140–153, 63, 59, 45–46; 2/426–432, 447–449, 441, 434–437, 2/13, 15; D21/483, 659–661; D14/372; D24/110.1; D28/9

CPC ..... G02C 2200/08; G02C 1/06; G02C 5/14; G01C 5/16

See application file for complete search history.

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*Primary Examiner* — Raphael Barkai(74) *Attorney, Agent, or Firm* — Luca D'Ottone; KB Patents(57) **CLAIM**

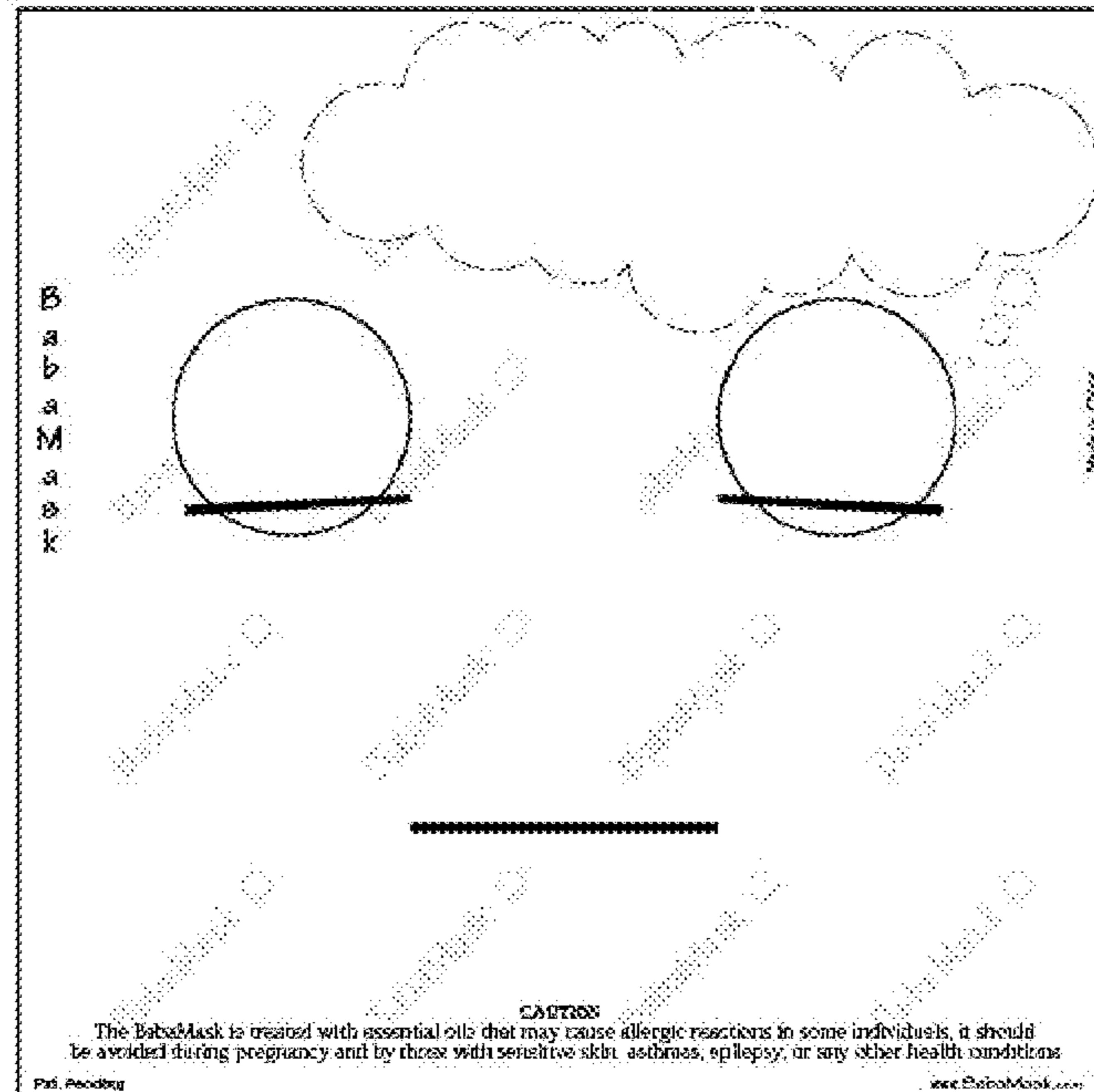
The ornamental design for a face mask, as shown and described.

**DESCRIPTION**

FIG. 1 is a front elevation view of a face mask, showing my new design; and,

FIG. 2 is a back elevation view thereof.

The area within the dashed lines is not part of the claimed design.

**1 Claim, 2 Drawing Sheets**

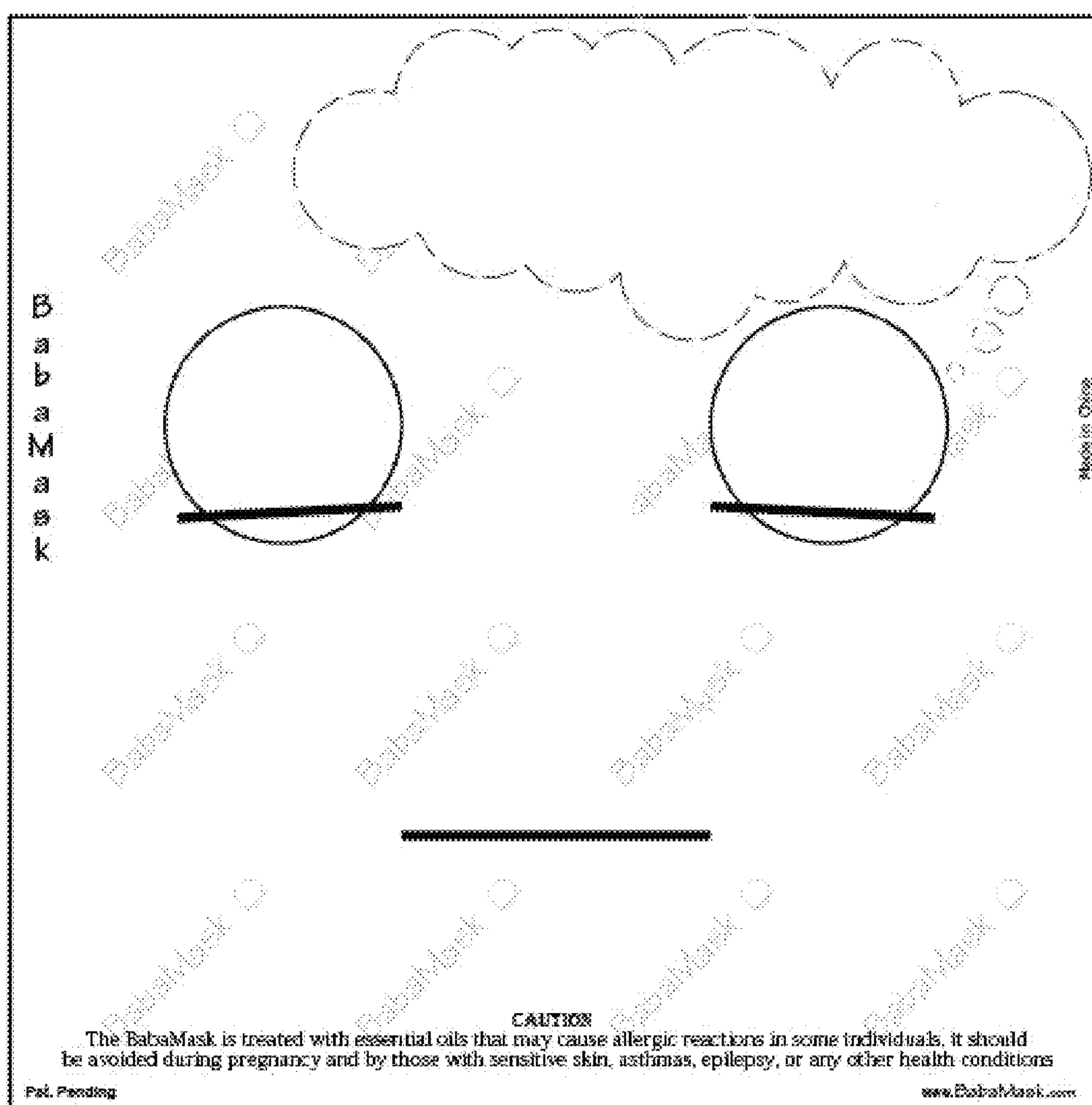


FIG. 1



**FIG. 2**